

L Number	Hits	Search Text	DB	Time stamp
1	1	5895223.pn.	USPAT; EPO; JPO; IBM_TDB	2002/12/13 12:36
2	1185	porous and (HF or Hydrofluoric) and etch\$5 and (Pt or platinum or Au or gold or Pd or palladium)	USPAT; EPO; JPO; IBM_TDB	2002/12/13 12:50
3	753	(porous and (HF or Hydrofluoric) and etch\$5 and (Pt or platinum or Au or gold or Pd or palladium)) and semiconductor	USPAT; EPO; JPO; IBM_TDB	2002/12/13 12:43
5	600	((porous and (HF or Hydrofluoric) and etch\$5 and (Pt or platinum or Au or gold or Pd or palladium)) and semiconductor) and electrodes	USPAT; EPO; JPO; IBM_TDB	2002/12/13 13:34
7	1829	electrochemical near4 etch\$5	USPAT; EPO; JPO; IBM_TDB	2002/12/13 12:50
8	111	(electrochemical near4 etch\$5) and (porous and (HF or Hydrofluoric) and etch\$5 and (Pt or platinum or Au or gold or Pd or palladium))	USPAT; EPO; JPO; IBM_TDB	2002/12/13 12:50
9	84	stain near etch\$5	USPAT; EPO; JPO; IBM_TDB	2002/12/13 13:35
16	131887	"porous silicon" or PSi	USPAT; EPO; JPO; IBM_TDB	2002/12/13 13:44
17	403	("porous silicon" or PSi) and (porous and (HF or Hydrofluoric) and etch\$5 and (Pt or platinum or Au or gold or Pd or palladium))	USPAT; EPO; JPO; IBM_TDB	2002/12/13 13:44
20	1372	((438/409) or (438/456) or (438/459) or (438/479)).CCLS.	USPAT; EPO; JPO; IBM_TDB	2002/12/13 13:56
21	45	((438/409) or (438/456) or (438/459) or (438/479)).CCLS.) and (porous and (HF or Hydrofluoric) and etch\$5 and (Pt or platinum or Au or gold or Pd or palladium))	USPAT; EPO; JPO; IBM_TDB	2002/12/13 13:56

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